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CLAIMS: Please amend the claims according to the status designations in the following list, which contains all claims that were ever in the patent application, with the text of all aritive

What I claim are:

1. (withdraw).

2. (withdraw).3. (withdraw).

4. (withdraw).

5. (wiftedraw).

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6. (withdraw).

7. (withdraw).

8. (withdraw).

9. (wiff.draw).

11. (withdraw).

16. (withdraw).

13. (withdaw).

13. (withdraw).

14. (Curently amended) A vertical serriconductor thip or device comprising

an electrically conductive submount chip;

an epitaxial layer comprising a second confinement layer, an active layer, and a first

confinement layer stacked on said submount chip;

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reflective and Otmic contact layers sandwiched between seid epizatial layer and seid

sutmount chip;

d) a patterned contact pad disposed on said first confinement layer wherein said patterned

contact pad comprising at least one wire bonding pad.

15. (withchaw).

16. (Comenty amended) The vertical semiconductor city or device of claim 14 further

comprising a current spreading layer sardwiched between said putterned contact pad and said

first confinement leyer.

17. (withdraw)

18. (Curently arrended) The vertical semiconductor chip or device of cluim 14 wherein said

patterned contact pad is a grid-ring-shaped contact pad with at least one wire bonding pad.

19. (withdraw).

21. (withdraw).

20. (withdraw).

22. (witt-draw).

25. (withdraw).

24. (withdraw).

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